

SiC and diamond as radiation hard semiconductor detectors



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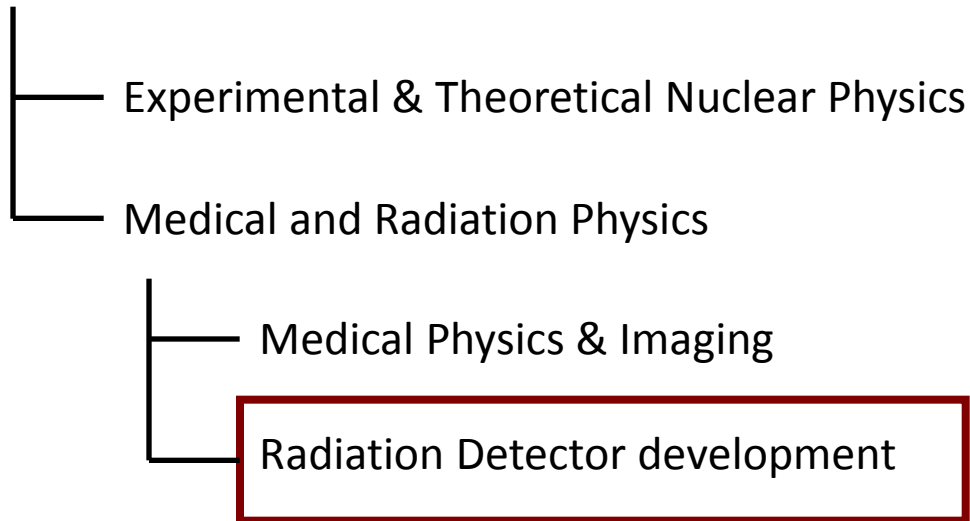
AWE

Department of Physics ~ 30 academics



Part of the Faculty of Engineering and Physical Sciences (FEPS)

- Soft condensed matter (SCM)
- Astrophysics
- Photonics & Semiconductor devices - Advanced Technology in collaboration with electronic engineering
- Centre for nuclear and radiation physics (CNRP)

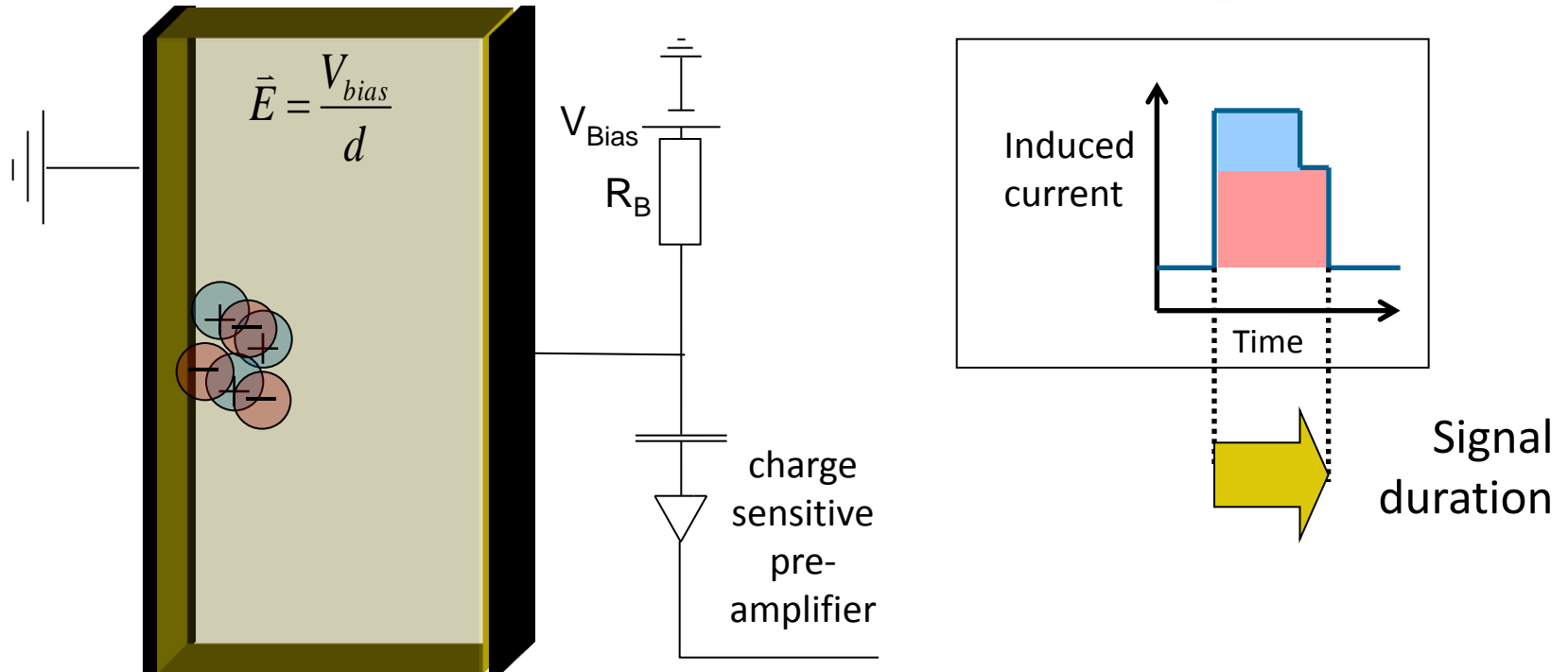


2 academics and approx. 12 research students

Talk outline

- Basic semiconductor detector operation
- Advantages of wide band gap semiconductors – Low Z
Radiation hard materials SiC/D
- (General) Effects of Radiation damage on semiconductor detector operation
- Quantifying “radiation hardness”
- Identifying created defects
- Conclusion – Future work

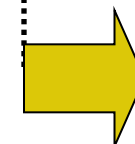
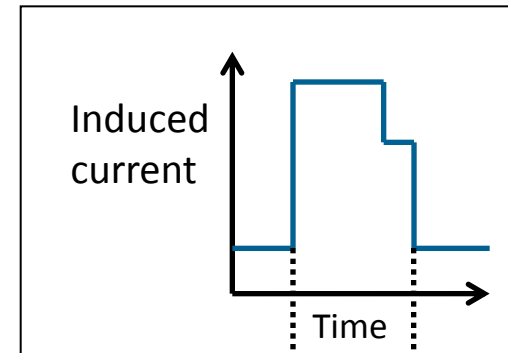
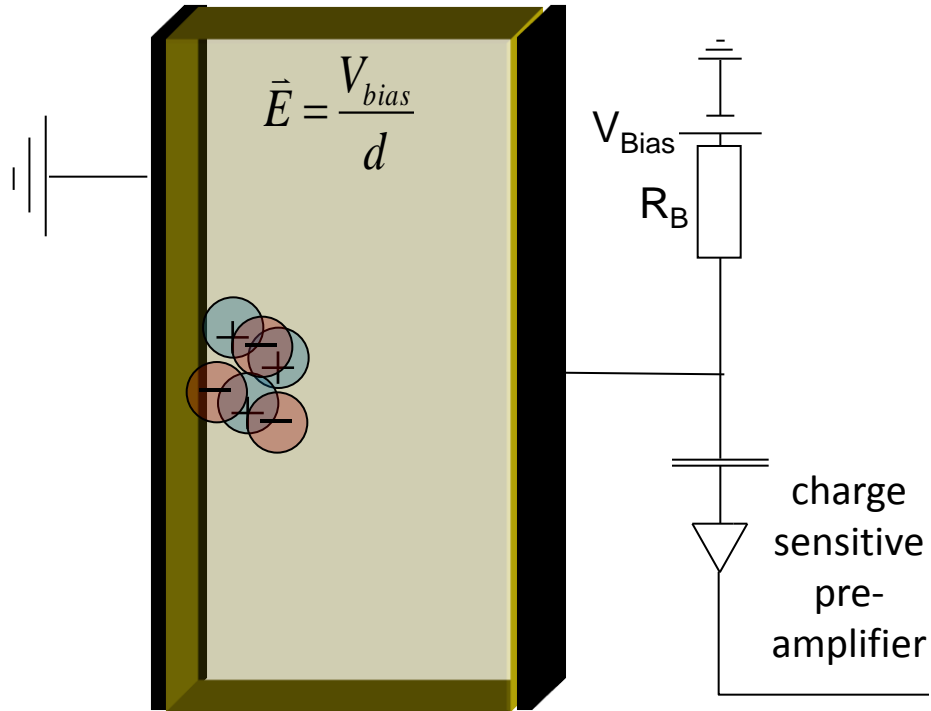
Signal formation



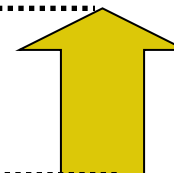
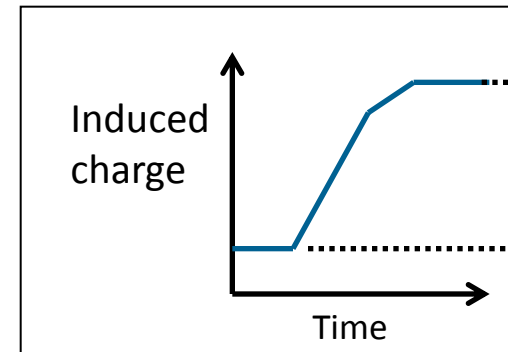
The current signal is induced by the movement of the created charge carriers: the current is proportional to

- the number of carriers \rightarrow lifetime $\tau >$ transit time T_R
- the charge carrier velocity \rightarrow mobility μ , electric field strength

Signal formation



Signal duration



Signal amplitude

Wide band gap semiconductor materials for room temperature radiation detector application



Application areas

- High energy and nuclear physics
- Neutron detection & monitoring in nuclear industry
- High energy X- and γ -ray detection for medical and security applications
- Photon science/Synchrotron instrumentation
- Medical dosimetry
- High fluence backgrounds and harsh environments
-

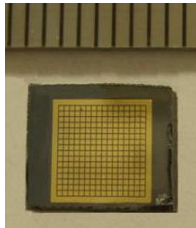
http://www.ptw.de/diamond_detector0.html



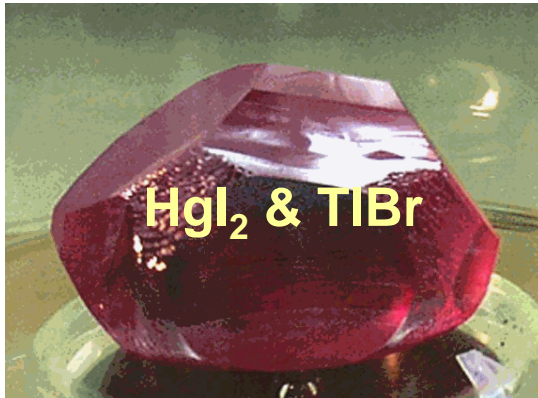
Commercially available PTW chambers based on natural diamonds

Two main groups of materials studied

High Z material for X/ γ
spectroscopy and imaging



$Cd_xZn_{1-x}Te$

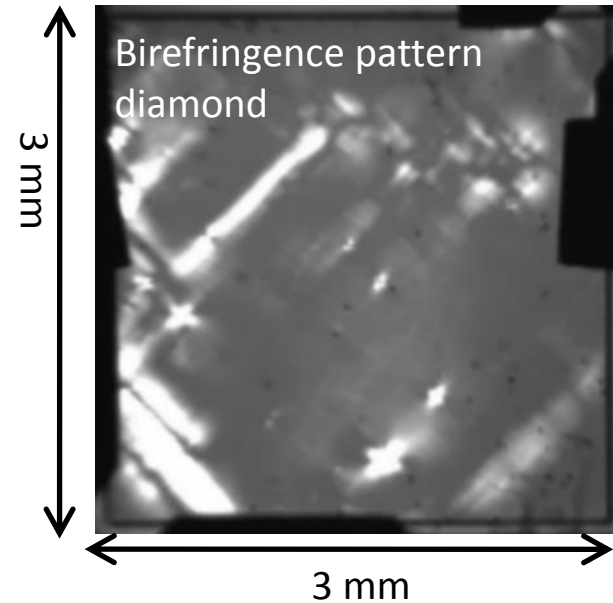


HgI_2 & $TlBr$

http://www.contech.com/Mercuric_Iodide_Detectors.htm

$CdTe$ $CdZnTe$
 HgI_2 $TlBr$

Radiation hardness/
Tissue “equivalent”
Neutron detection, TOF

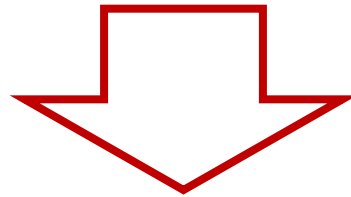


Diamond SiC
polymers

Diamond & SiC for sensor applications



- Large heat conductance
- Low Z (low absorption)
- Tissue equivalence*
- Wide band gap (solar blind)
- Fast charge transport *
- Tissue equivalence*
- (Radiation) hardness*



UV sensor

Neutron detection

(X-ray) Dosimetry

(s)LHC

Beam monitor

* stronger advantage in diamond compared to SiC

Attractive properties for detector applications (II)

Large band gap

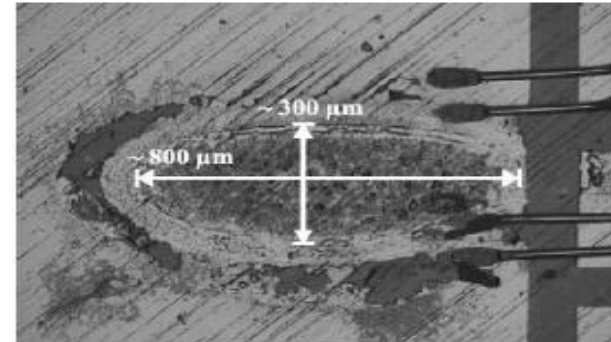
- ⇒ “solar blind” (UV detection)
- ⇒ (low intrinsic leakage currents)
- high temperature operation

Large heat conductance (5 x copper)

Resilience

- ⇒ Chemically inert
- ⇒ Radiation hardness

80 μm thick pc CVD diamond detector with Al contact



1 μs bunches of 10^9 of $^{208}\text{Pb}^{67+}$ ions (400 MeV/u = 83.2 GeV).
=> Stable signal (in the order of mpere)

J. Bol et al., phys. stat. sol. (a) 204, 9, pp. 2997-3003 (2007)



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Nuclear Instruments and Methods in Physics Research A 546 (2005) 222–227

NUCLEAR
INSTRUMENTS
& METHODS
IN PHYSICS
RESEARCH
Section A

www.elsevier.com/locate/nima

Diamond radiation detectors may be forever!

H. Kagan*

Department of Physics, Ohio State University, Columbus, OH 43210, USA

Available online 4 May 2005

On behalf of the RD42 Diamond Detector Collaboration

Challenges in the material synthesis

Diamond is meta-stable:

- High Temperature/High Pressure (HP/HT) limited volume, purity

• Chemical vapour deposition (CVD)

- Heteroepitaxy (typically polycrystalline – large area possible)

Diamond on Iridium might be able to provide sufficiently thick, homogenous large areas in the future

- Homoepitaxy (typically $< 1 \text{ cm}^2$ area)

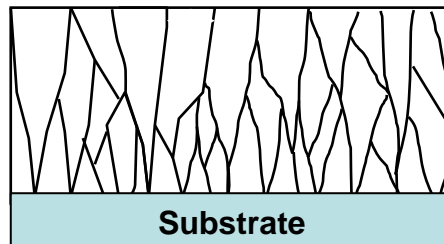
Several polytypes of SiC exist

- Physical Vapour Transport (bulk – single crystal)
- Chemical vapour deposition (CVD)

Common defects

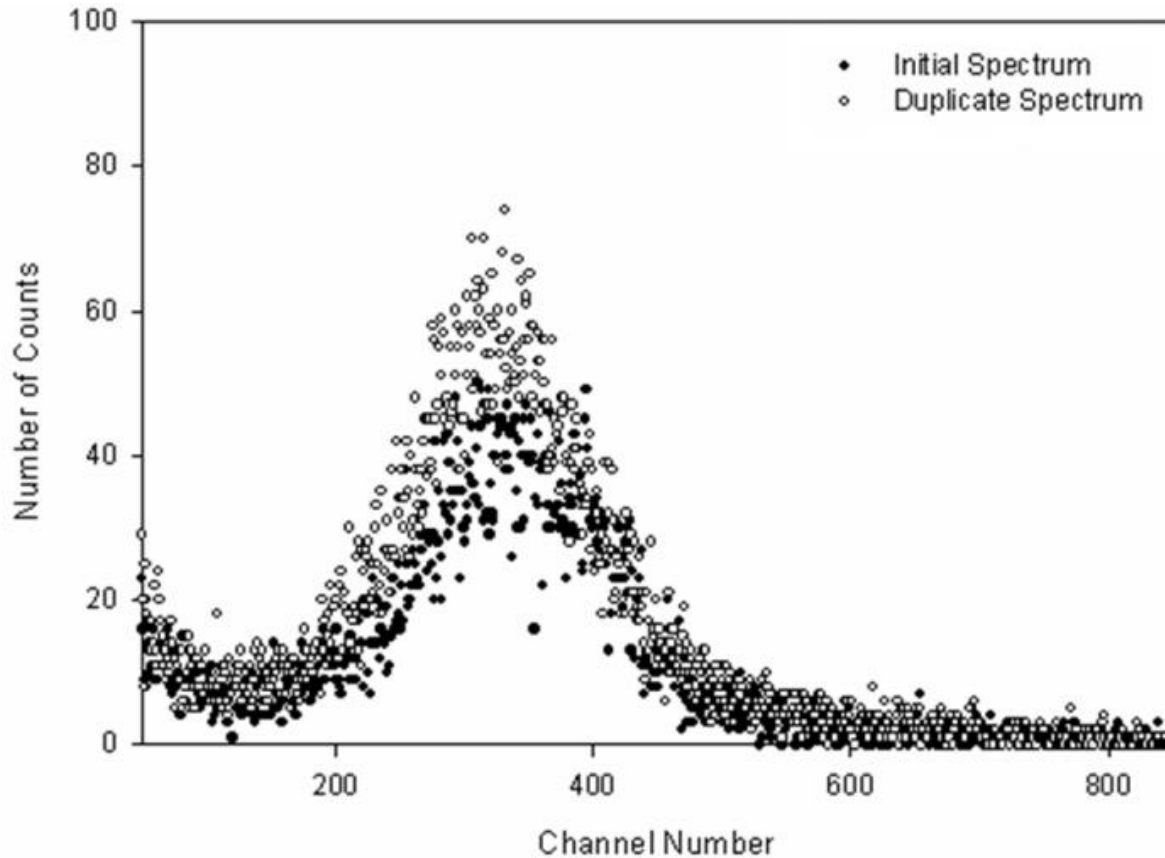
Impurities, vacancies,
Interstitials
Dislocations
Grain boundaries
Stacking faults
Polytype inclusions

**Columnar growth
increasing grain size
towards the top**



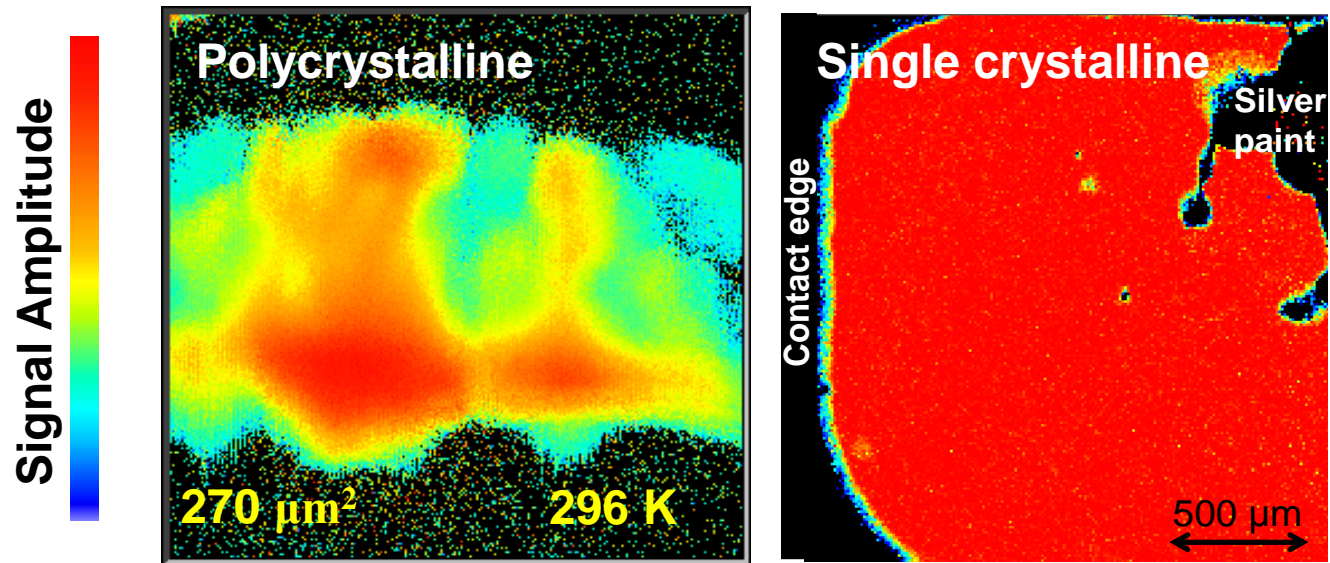
**1 to 10
 $\mu\text{m h}^{-1}$**

SiC - thick (350 μm) “bulk” material



Bryant et al, IEEE TNS 60(2), pp. 1432 – 1435, 2013

Non-uniform response in polycrystalline material



Electronic grade single crystal detector



performance

**Energy resolution similar
to Silicon**

**Time resolution, time of flight:
28 ps**

See Figure 8 and 9 in M. Pomorski et al. *phys. stat. sol. (a)* 203 (12), pp. 3152-3160 (2006) DOI: 10.1002/pssa.200671127

See Figure 22 in M. Ciobanu, *IEEE TNS* 58 (4), pp. 2073-2083 (2011)
DOI: [10.1109/TNS.2011.2160282](https://doi.org/10.1109/TNS.2011.2160282)

Towards large area single crystals



Images from E. Berderman et al, 3rd Carat Workshop at GSI, Dec 2011

Heteroepitaxial growth on Iridium – large area substrates possible

Main European player: M. Schreck et al in Augsburg/Germany

For illustrations see:

http://www-carat.gsi.de/CARAT03/CARAT03Talks/Berdermann_CARAT03.pdf

Slide 4 and 14

Continuously improvement in thickness, quality and area with time

Towards more radiation hardness



Images from B. Caylar et al, 1st Adamas Workshop at GSI, Dec 2012

For illustrations used see:

<http://www-adamas.gsi.de/ADAMAS01/talks/caylar.pdf>

Slide 5 and 19

Several groups have demonstrated working devices:

Full CCE reached at very low applied bias (operate detectors with a 9V battery is possible)

SiC - excellent Schottky diodes for Spectroscopy have been demonstrated

Figure 2 in Ruddy et al, Nucl. Instr. Meth. B 263 (2007) 163-168
[doi:10.1016/j.nimb.2007.04.077](https://doi.org/10.1016/j.nimb.2007.04.077)

High Temperature spectroscopy in epitaxial SiC Schottky diodes developed by RD50)

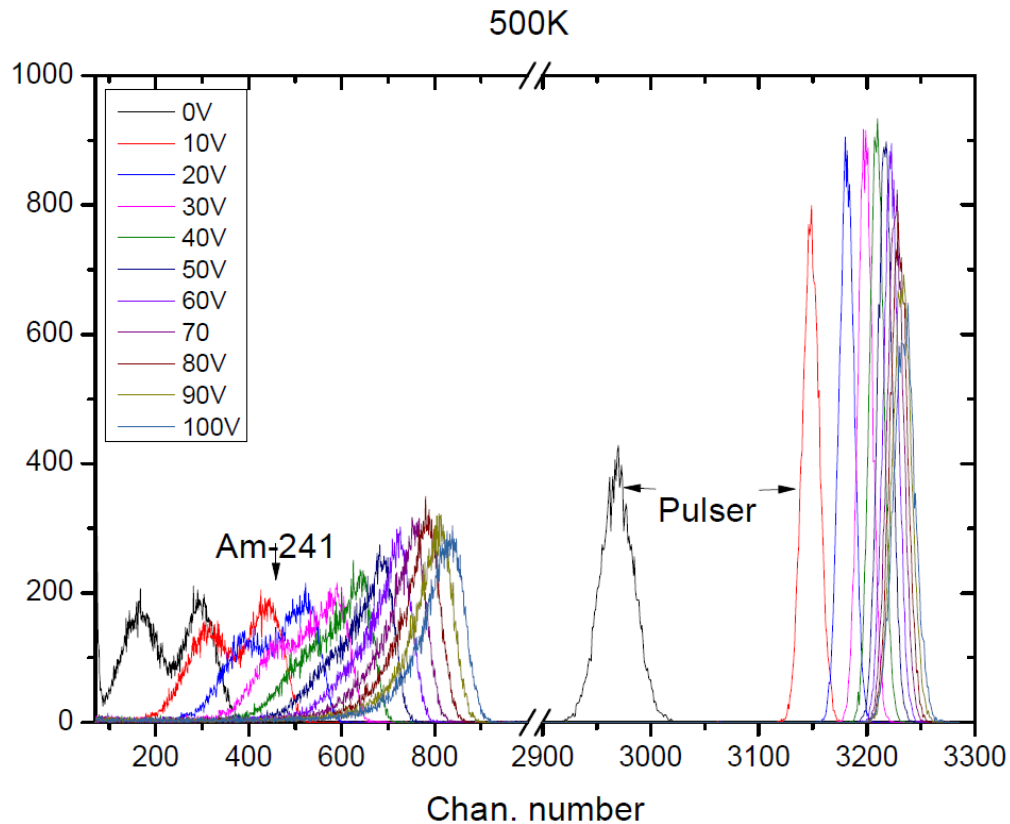
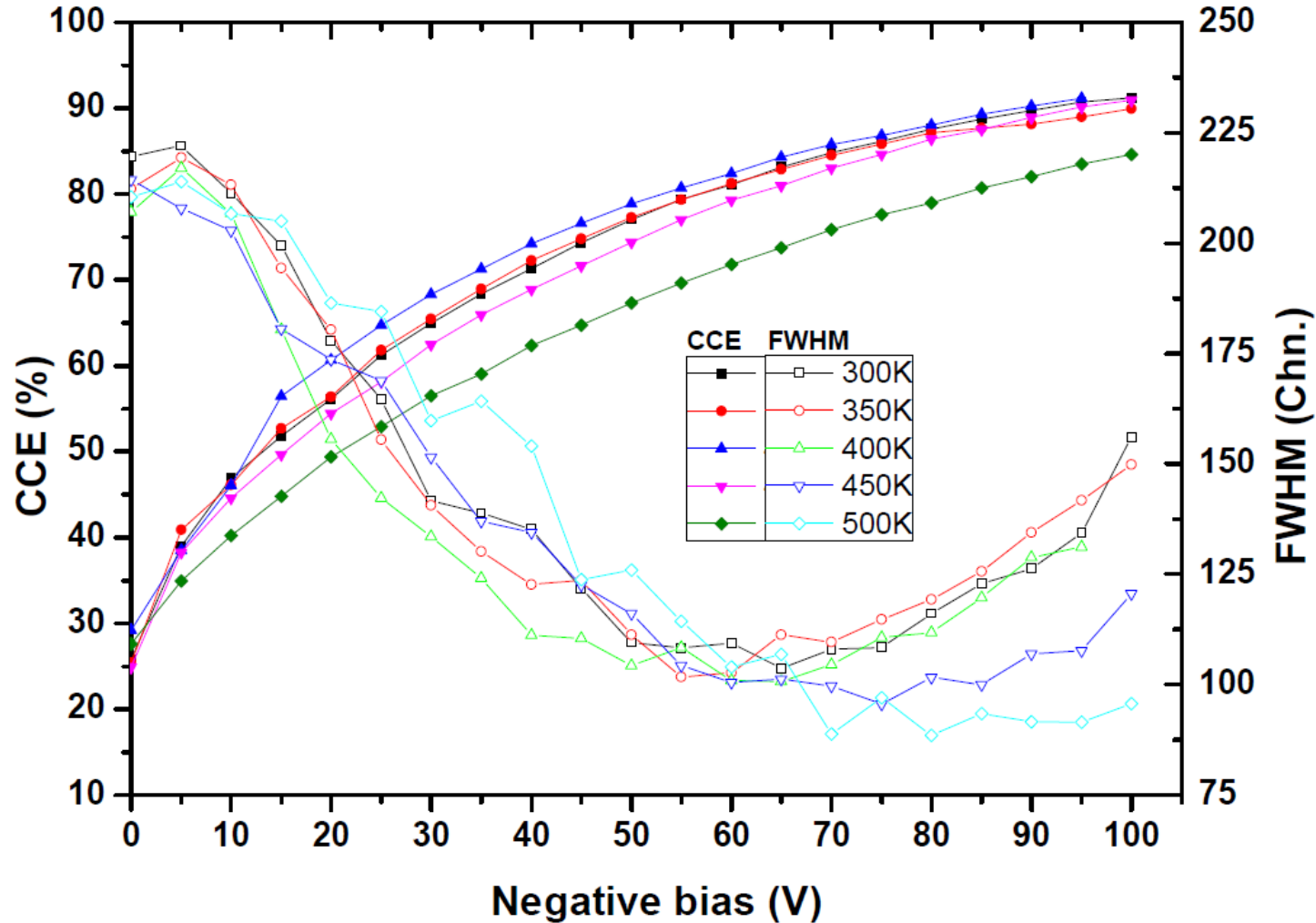


Figure 1 in C. Manfredotti et al., Nucl. Instrum. Meth. A 552 (2005) 131–137
[doi:10.1016/j.nima.2005.06.018](https://doi.org/10.1016/j.nima.2005.06.018)

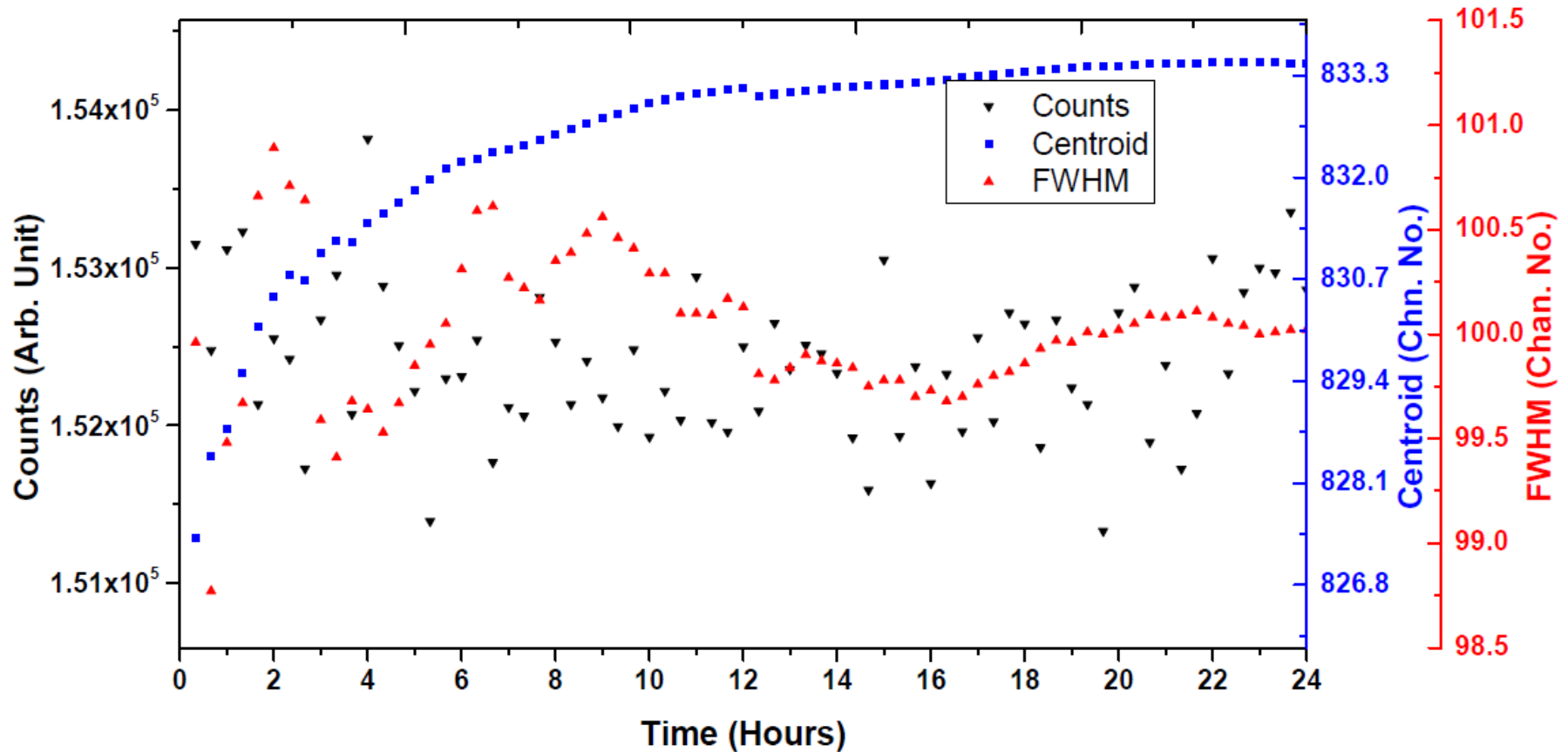
Alpha emission energy spectrum broad with average energy at 5 MeV

(Due to encapsulation of source to be safe to use at elevated Temperature)

High Temperature spectroscopy in SiC



High Temperature spectroscopy in SiC



Stability tests under fast neutron and gamma irradiation at room temperature show of epitaxial and bulk SiC samples also show good stability at 4.5 to 18.5 mSv/hour (AmBe Source, Co-60)

Creation of defects due to irradiation

$E_K = 60 \text{ keV}$

4 fold

Energy transfer to the lattice atoms moves them from a substitutional to an interstitial site:

**→ Creation of [V – C_i]
(Frenkel pair)**

Dissociation and diffusion then can lead to many more defect Complexes.....

*International Journal of Modern Physics C 9, p1x
1998, D. Saada, J. Adler, and R. Kalish*

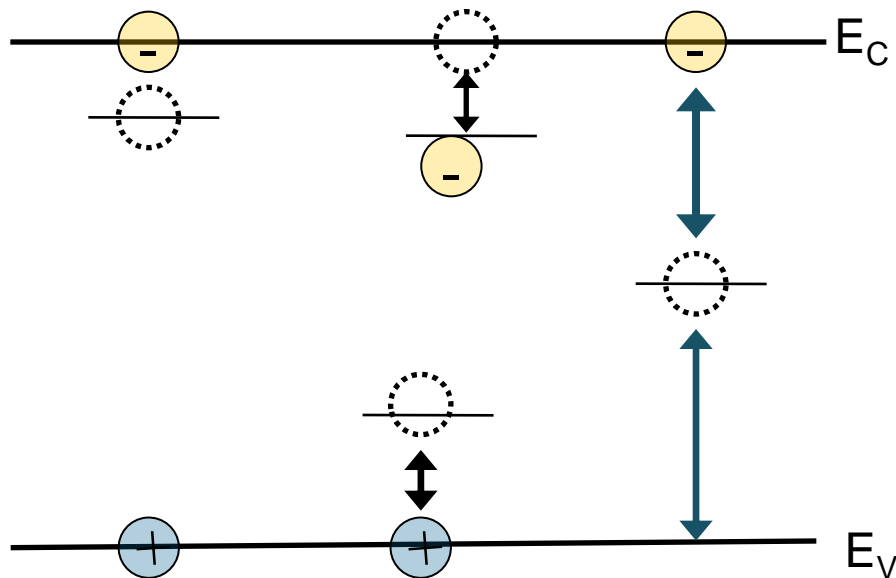
*K. Schmetzer, The Journal of
Gemmology / 2010 / Volume 32 /
No. 1–4*



Annealing can change the defect types and concentrations further

Effect of damage on electrical properties

... changes the type/concentration of defects present in the material and hence introduces/removes energy levels in the band gap



- “Close” to E_C / E_V :
Dopants
- Near “mid gap”:
Recombination centres

Effect of damage on electrical properties

... changes the type/concentration of defects present in the material and hence introduces/removes energy levels in the band gap

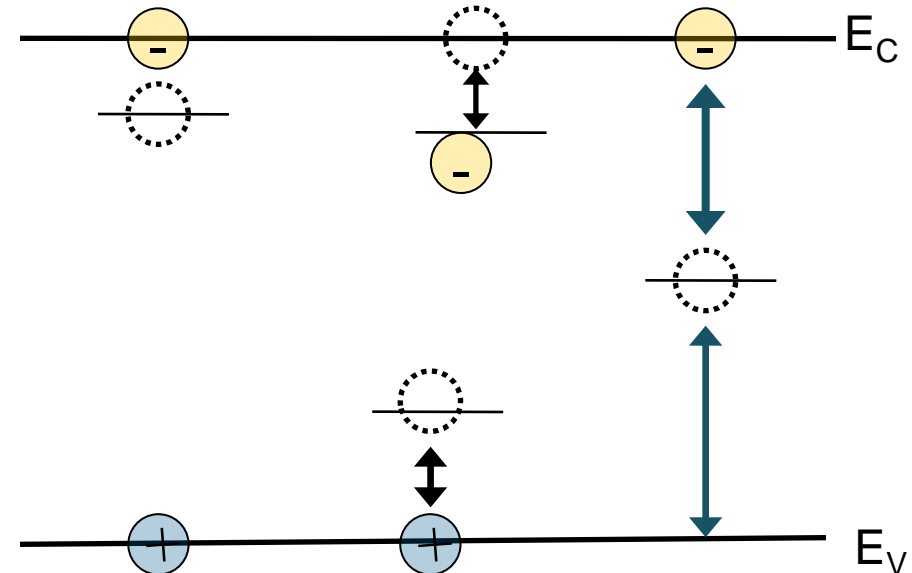
Leakage current:

In an “ideal” intrinsic semiconductor, free charge carrier density is given by

$$n \approx N_C \exp\left(-\frac{E_G}{2k_B T}\right)$$

N_C , density of states in the conduction band
 $\sim 10^{19}\text{cm}^{-3}$

Large E_G gives lower dark currents, but experimentally “intrinsic” leakage current dominated by free carriers from defect states in the band gap



Effect of damage on electrical properties



- **increase leakage**
 - increase in effective doping
- **reduce leakage**
 - Compensation (reduction in doping)
 - Reduction in carrier life time (recombination)

Signal acquisition:

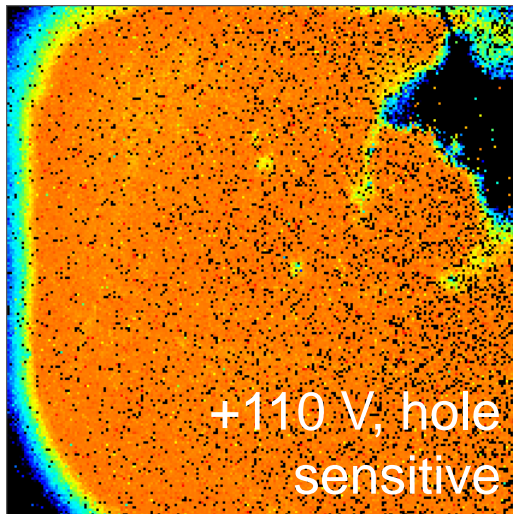
- Reduction in free carrier lifetime – possibly reduced signal
- Trapping/De-trapping – “slower” signal
- Reduction in active thickness (depletion thickness depends on doping in diodes)

Polarisation a contact problem?

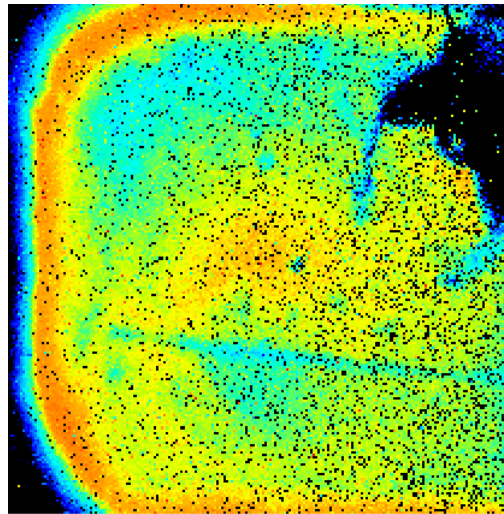
Surface and temporary effects:

- “temporary” changes in space charge distribution (polarisation)
- increase in number of occupied traps – increase in lifetime (priming)

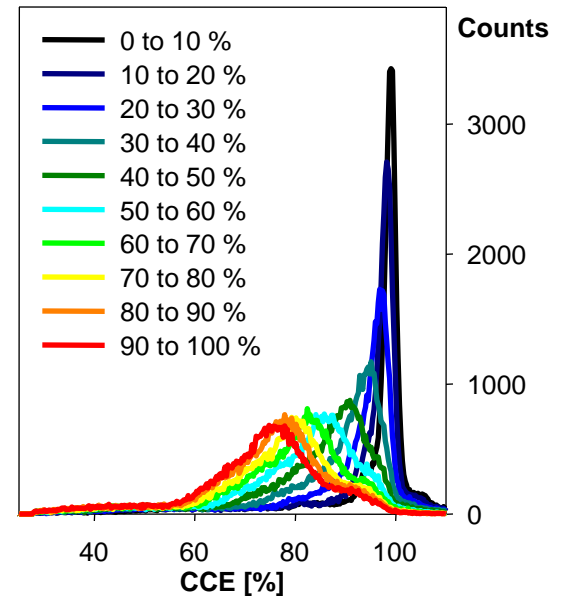
(a) 0 to 20 % of the data file



(b) 80 to 100 % of the data file



(c)



Inconsistencies as a function of contacting method also observed by W. DeFerme, Hasselt Diamond Workshop 2009

The challenge of quantifying radiation hardness for detector applications



The NIEL concept – assumes displacement damage cross-section D (MeV mb) – assumes that lifetime scales with # displacements

Seems to work for protons/neutrons > 0.1 GeV

Figure 4 De Boer, phys. stat. sol. (a) 204, No. 9, 3004–3010 (2007)
DOI: 10.1002/pssa.200776327

Damaging radiation and probing radiation penetrate through the device thickness.

(26 MeV H⁺/ 20 MeV n/ MIPs)

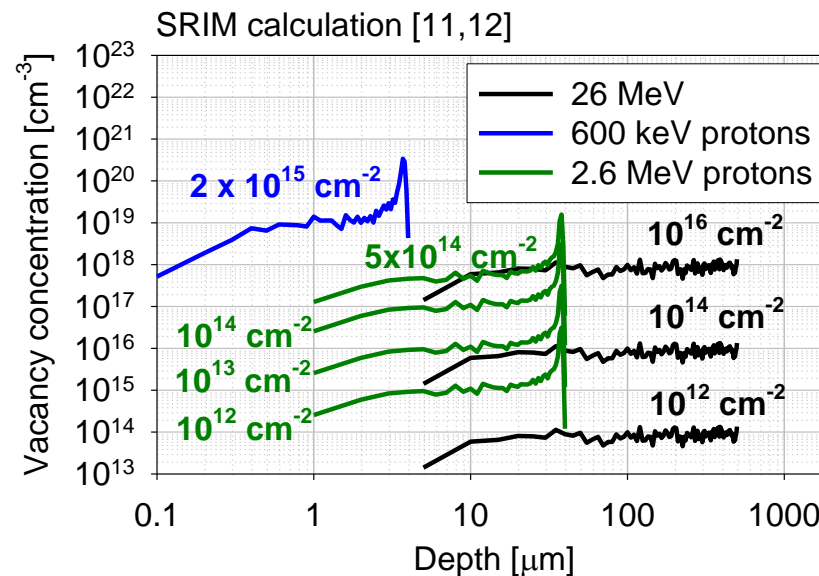
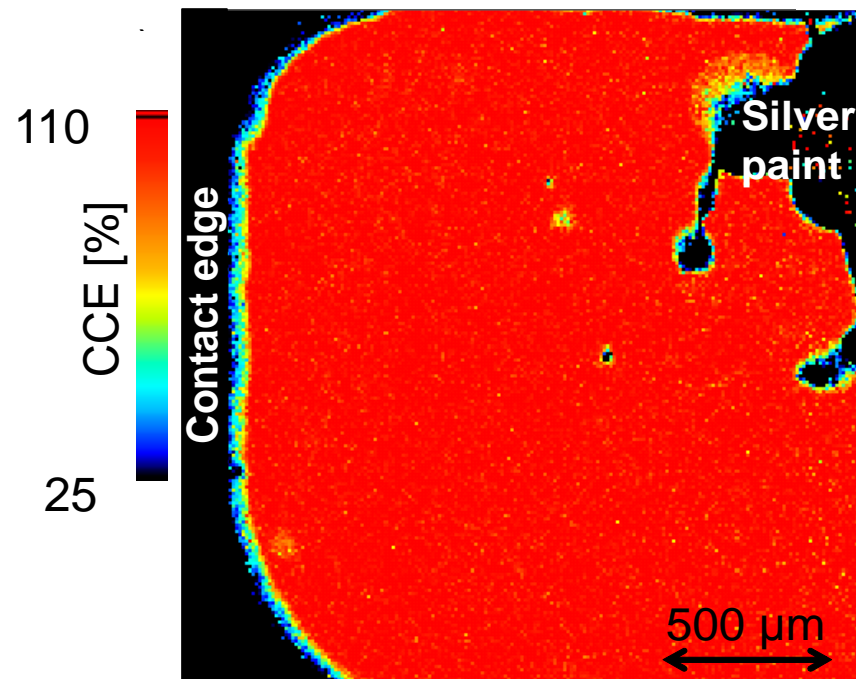
Signal halves after

p: 4.5 (1.5)x10¹⁴ cm⁻²

n: 1.3 (3)x10¹⁵ cm⁻²

The challenge of quantifying radiation hardness for detector applications

What if the damaging/probing radiation does not penetrate the whole device?

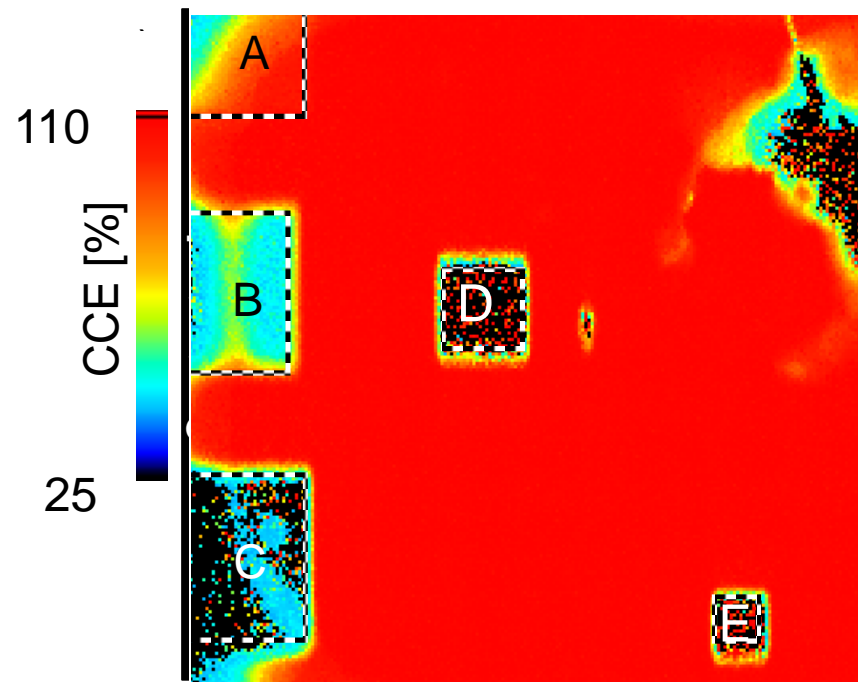


A. Lohstroh et al, *phys. stat. sol. (a)* 2008, 205(9); p.2211-2215

Damaged area not visible in Raman spectra

The challenge of quantifying radiation hardness for detector applications

What if the damaging/probing radiation does not penetrate the whole device?



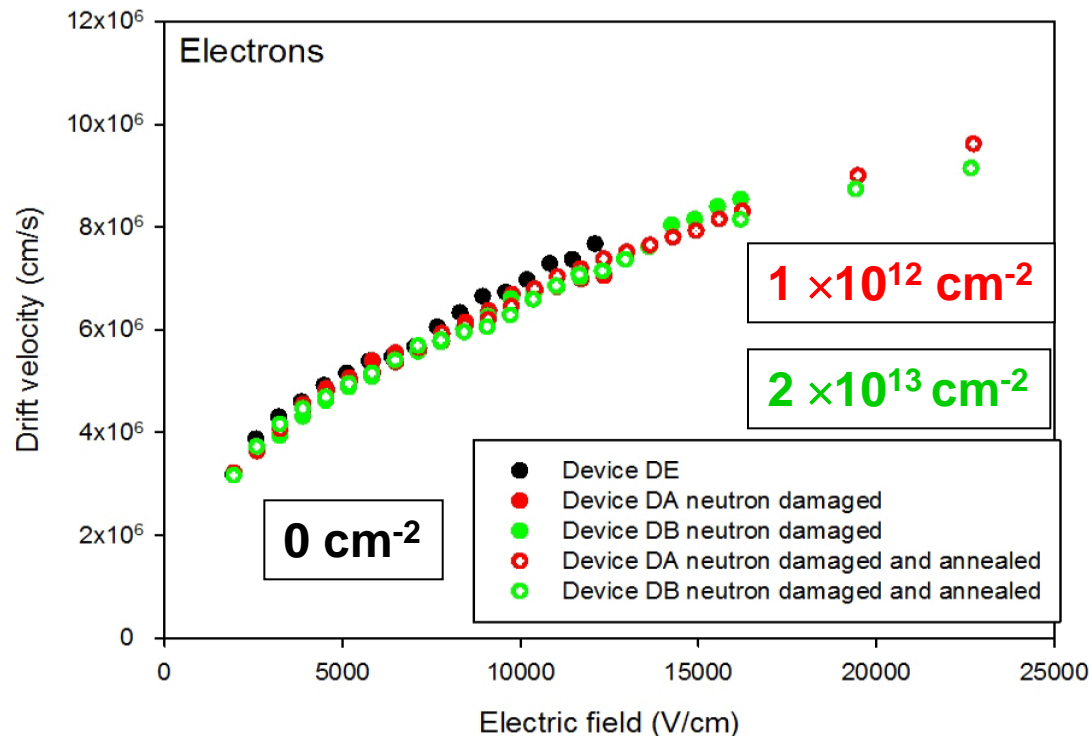
Label	Area [10^{-3} cm^2]	Dose [cm^{-2}]
A	2.6 ± 0.3	$(1.1 \pm 01) \times 10^{12}$
B	2.4 ± 0.3	$(1.1 \pm 01) \times 10^{13}$
C	2.6 ± 0.3	$(1.0 \pm 01) \times 10^{14}$
D	0.6 ± 0.14	$(5 \pm 1) \times 10^{14}$
E	0.18 ± 0.08	$(1.0 \pm 0.4) \times 10^{15}$
F	0.05 ± 0.04	$(5 \pm 4) \times 10^{15}$

A. Lohstroh et al, *phys. stat. sol. (a)* 2008, 205(9); p.2211-2215

Damaged area not visible in Raman spectra

TOF/TCT measurements ...

... confirms that damage does not have a strong effect on mobility compared to lifetime (in Diamond)



S. Gkoumas, PhD thesis,
University of Surrey 2012

$$\mu_0 = (1600 \pm 100) \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$$
$$v_{\text{sat}} = (1.20 \pm 0.05) \text{ V cm}^{-1}$$

Introducing a “corrected” Damage factor



- Assume that trapping probability increases linearly with radiation fluence
- Take into account damage profile (e.g. SRIM or other code)
- Ionisation profile of probing radiation (e.g. SRIM or other code)

Z. Pastuovic et al, Proc. of SPIE Vol. 8725 87251A-1

Figure 4,5, 6

doi:10.1117/12.2015541

**Works well for
“low level
damage in
Silicon”**

**=> Needs to be
demonstrated in
wider range of
materials**

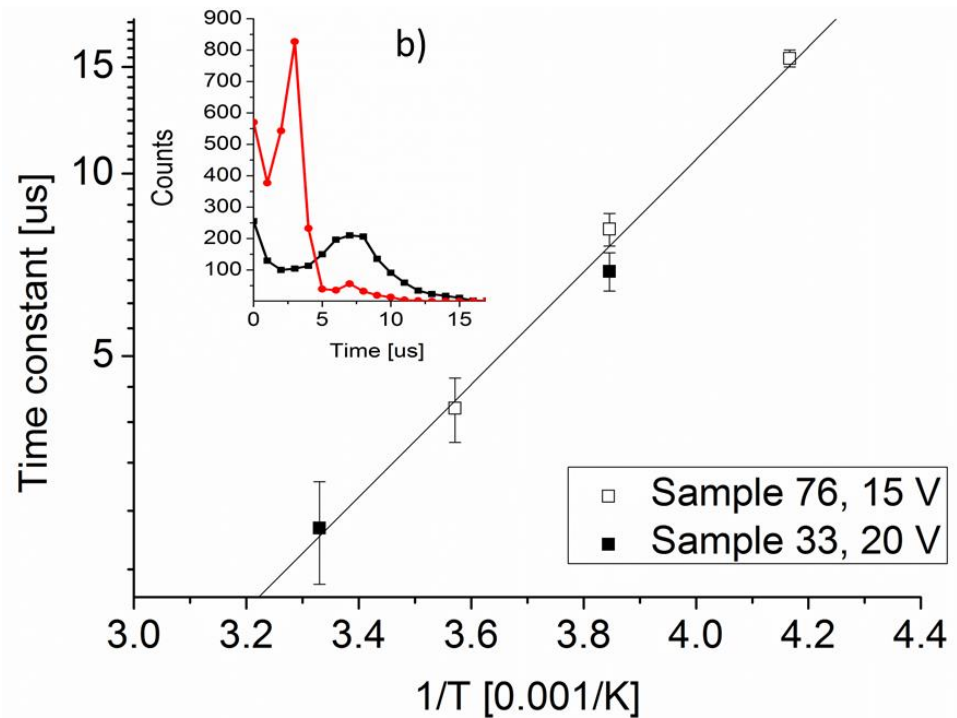
IAEA (CRP: F11016-CR-2)

Identifying defect levels that affect the detector signal

Defect characterisation in semiconductors

- **DLTS** not useful for high resistivity
- **PICTS** light source/limited time scale
- **Luminescence** not quantitative/
cannot see non-radiative defects
- **Optical absorption** detection
limits/sample size
- **EPR** sample size, only sensitive to
paramagnetic
- **PAS** sample size
- ...

Direct observation of damaged detector signals



IAEA (CRP: F11016-CR-2)

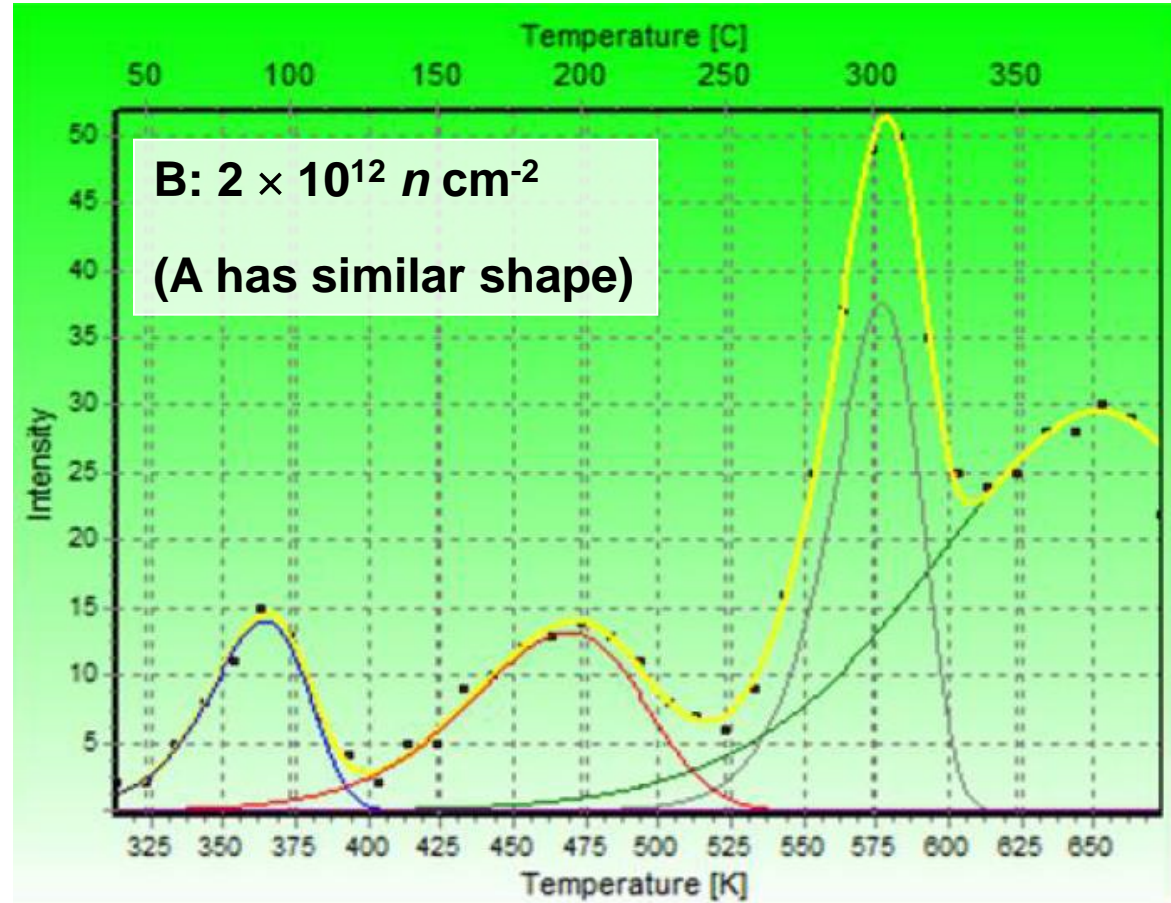
TL - after annealing

20 Gy pre-irradiation – 313 K to 650 K, 10 K/s

$1 \times 10^{12} n \text{ cm}^{-2}$: 0.5 eV
0.6 eV
1.7 eV
0.7 eV

$2 \times 10^{13} n \text{ cm}^{-2}$: 0.6 eV
0.6 eV
1.8 eV
0.6 eV

$1 \times 10^{16} n \text{ cm}^{-2}$: 0.6 eV
0.6 eV
0.8 eV
0.9 eV

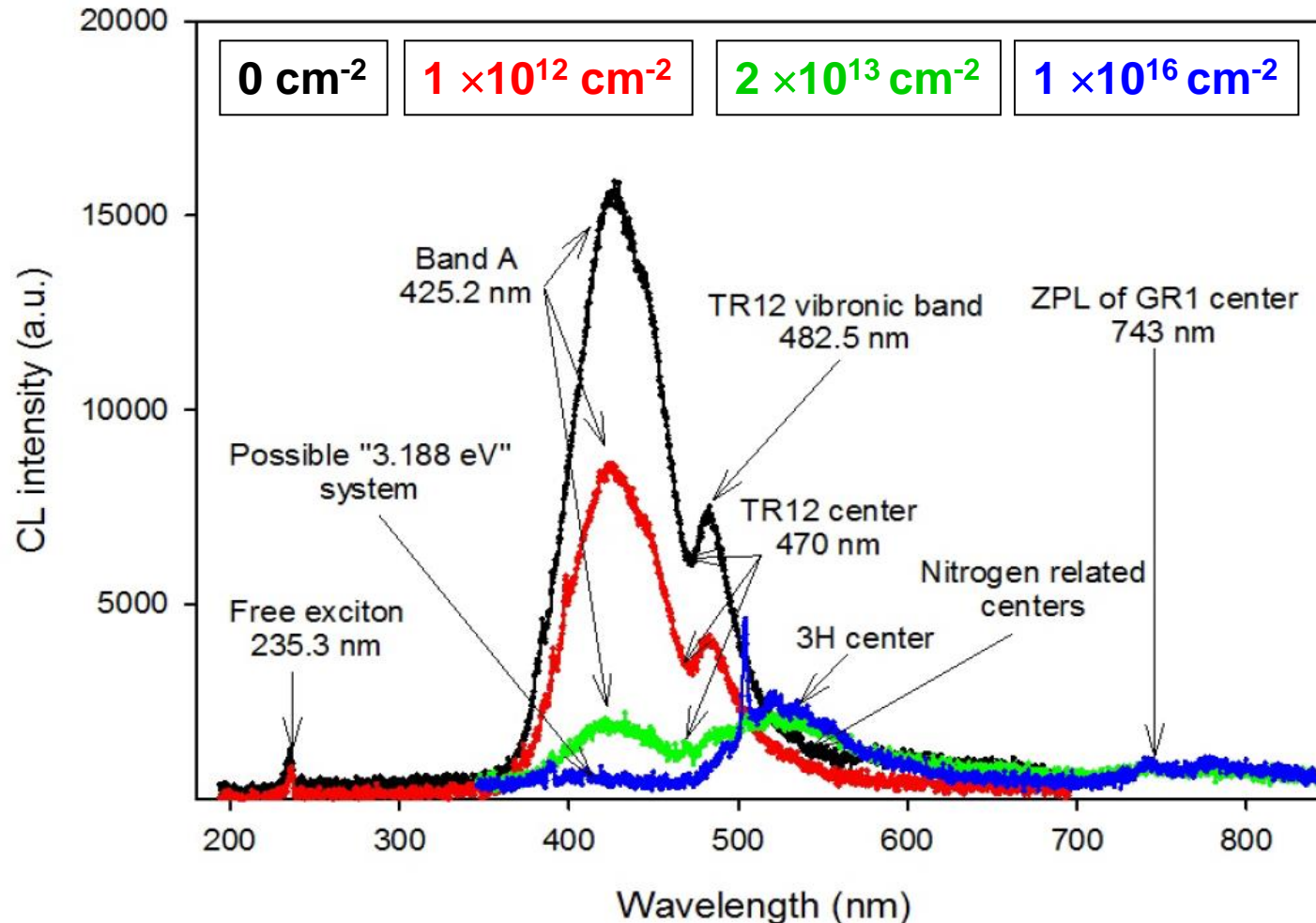


In pc: 1.8 to 1.9 eV observed by

*Gonon et al. (APL 70 (1997) 2996-2998) and
Benabdesselam et al. (DRM 10 (2001) 2084-2091)
(substitutional Nitrogen?)*

CL - before annealing

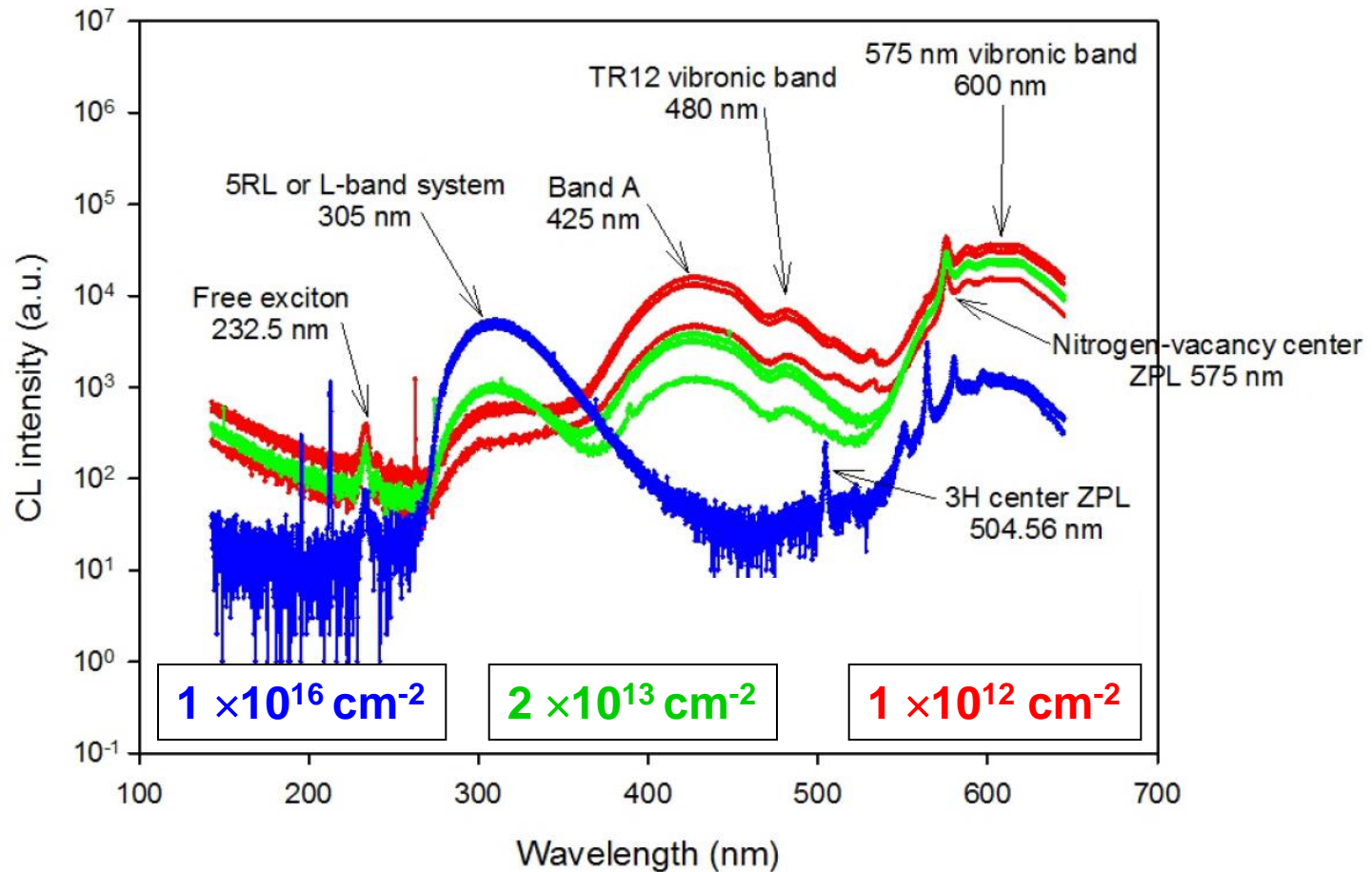
S. Gkoumas, PhD thesis,
University of Surrey 2012



3H and "3.188 eV" centre – also seen in neutron irradiation study
Almaviva et al JAPP 106 (2009) 073501

Reference for defect levels: A. M. Zaitsev, *Optical Properties of Diamond: A Data Handbook*, Springer-Verlag, Berlin – Heidelberg, 2001

CL - after annealing



CL - summary

Before annealing After annealing

λ [nm]	E [eV]	0 ncm ⁻²	A: 1×10^{12} ncm ⁻²	B: 2×10^{13} ncm ⁻²	C: 1×10^{16} ncm ⁻²
235	5.29	✓	✓✓	✓	✓
305	4.07				
389	3.19				
425	2.92	✓	✓✓	(✓) ✓	(✓)
470	2.64	✓	✓		
503	2.47				✓
533	2.33	✓	✓		
575	2.16	✓	✓✓	✓	✓
741	1.67			(✓)	✓

Free Exiton

5RL - self interstitial or L band

Known as damage signature

Band A - dislocations

TR12

3H - interstitial

N-related

[N-V]₀

GR1 (single neutral vacancy)

Conclusion

- Estimating the operational lifetime of detectors needs more understanding of the effects of radiation induced damage on their characteristics – including self annealing
- In wide band gap semiconductors, separating priming/polarisation and structural damage is challenging
- “Radiation hardness” as a material property independent of radiation and probe is not trivial
- Improving our understanding of hardness and defect characteristic with the help of IAEA coordinated research programme

Thank you!



Questions?